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<u>10th World</u>	Micromachine Summ
May 3 rd - 5 th	Grenoble, Franc

Sunday, May 2	
19.00 - 21.00	Welcome cocktail at Grand Hotel Mercure Président
Monday, May 3	
8.00 - 9.00 9.00 - 9.15	Registration at Grand Hotel Mercure President Opening Ceremony
1. Country Re	view
9.15	Ian Bates, Australia RMIT University
9.30	Albert Van Den Berg, Belgium University of Twente
9.45	Dan Gale, Canada Canadian Microelectronics Corporation
10.00	ZhaoYing Zhou, China Tshinghua University
10.15	Piotr Grabiec, European Delegation / Poland Institute of Electron Technology
10.30	Coffee Break
11.00	Emmanuel Bigler, France ENSMM & FEMTO-ST
11.15	Roland Zengerle / Henning Wicht, Germany IMTEK / WTC
11.30	Shiban K Koul, India IIT - Indian Instititute of Technology Dehli
11.45	Igal Klein, Israel Israeli Society of MOEMS, DDR&D, RAFAEL
12.00	Takayuki Hirano, Japan Micromachine Center
12.15	Young-Ho Cho, Korea Digital Nanolocomotion
12.30	Paolo Dario, Mediterranean Region

SSSA - CRIM Lab

12.45	Henrik Jacobsen, Nordic Region
	Vestfold University College

- 13.00 Lunch
- 14.00 Siak Piang Lim, Singapore National University of Singapore
- 14.15 Nico de Rooij, Switzerland University of Neuchatel
- 14.30 Chih-Kung Lee, Taiwan National Taiwan University
- 14.45 Geoff Beardmore, United Kingdom Myriad Technologiy
- 15.00 Michael Gaitan, USA NIST Semiconductor Electronics Division
- 15.15 Coffee Break
- 2. Government policy, National programs and Infrastructures

15.45	Strategy in 'integrated Micro-Nano-Systems': From add-on to silicon into a new research field and emerging new industry Dirk Beernarert, European Commission
16.00	NEXUS / EURIMUS Gaëtan Menozzi, France MEMSCAP SA, Chairman of NEXUS and EURIMUS
16.15	Major new infrastructure facility and an associated R&D programme Geoff Beardmore, UK Myriad Technology

- 16.30 CNRS basic research on Micro and Nanotechnologies Michel de Labachelerie, France CNRS - FEMTO-ST
- 16.40 Accelerating Innovation: the MINATEC initiative David Holden, France CEA-Léti/MINATEC
- 16.50 Military applications of Microsystems policy and strategy in France Xavier Grison, France DGA

3. Education

17.00	Microtechnology education in Norway Per Ohlkers, Nordic Region Vestfold University College, Norway
17.15	Multimedia tool for understanding and explaining microsystems Philippe Fisher, Switzerland FSRM
17.30	Networking on behalf of education and training in micro and nano technologies Dan Dascalu, European delegation National Institute for R&D in microtechnologies, Romania
17.45	Comparison of Australian microtechology postgraduate masters programs with European programmes Ian Bates, Australia RMIT University
18.00	End of day 1
19.00	Departure for dinner at Château de Sassenage

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Tuesday, May 4

4. Industrial developments in MNT (Micro & Nano Technologies)

8.45	A case study on SENSONOR AS - The long way from R&D to volume production Henrik Jacobsen, Nordic Region Vestfold University College, Norway
9.00	Top down nanotechnology: assembly based manufacturing Tom Cellucci, USA Zyvex
9.15	MEMSCAP Publicly listed company Jean Michel Karam, France MEMSCAP SA
9.30	MEMS for watches Nico De Rooij, Switzerland University of Neuchâtel
9.45	MOEMS - Finding the way getting through industrial technologies Shiu Sche, Taiwan Neostones Microfabrication Corporation
10.00	Make MEMS an industry Dacheng Zhang, China Institute of Microelectronics, Pekin University, First MEMS Co. Ltd.
10.15	MASMICRO: Integration of manufacturing systems for mass manufactures of miniature/microproducts Thomas Maillard, European Delegation CEDRAT Technologies, France
10.30	Coffee break
11.00	Creating a successful MEMS company: a case study Chris Lumb, Canada, MICRALYNE Inc.
11.15	The expectations on integrated MEMS devices in ITS vehicles Kunihiko Hara, Japan DENSO Corporation

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11.30	Commercialization issues for the emerging micro-
	Nanosystems Industry David Tolfree, United Kindgom
11.45	Technopreneur Ltd. Waffer engineering for MEMS
	Veli Matti Airaksinen, Nordic Region HUT, Finland
12.00	MEMS projects in TeraOpt
	Miriam Hershkovitz, Israel TeraOpt
12.15	Development of the AECM microtechnology systems at
	RMIT: A case study Ian Bates / Jason Chaffey, Australia
	RMIT Universityµ
12.30	Industrial infrastructure and services for micro /
	nanotechnologies - A world wide assessment Patric Salomon, Germany
	4M2C Patric Salomon GmbH
12.45	Status of the MEMS industry
	Jean Christophe Eloy, France Yole Développement
13.00	Lunch
13.00	Euricii

5. Future Outlook - Advanced research in MNT

14.00	Promoting microfluidics as a new research strategy Yong Chen, France ENS - CNRS/LPN
14.15	Heading towards nano-bio: the reality check Ed Bell, United Kingdom Crown Microsystems
14.30	Human++: Autonomous sensors for health and comfort monitoring Chris Van Hoof, Benelux Region IMEC, Belgium
14.45	MEMS and Nanotechnology in ITRI Tung-Chuan Wu, Taiwan MIRL/ITRI

15.00	Integration of European research in Multi-Material Micro Manufacture within the EC FP6 programme Stephan Dimov, European delegation Cardiff University, Scotland
15.15	Prospects in microfluidics Anne Marie Gué, France CNRS/LAAS
15.30	Making contacts to individual molecules Peter Grutter, Canada Mc Gill University
15.45	Coffee break
16.15	Short comments on biochemistry Toshiro Shimoyama, Japan Olympus Corporation
16.30	Comb Drive actuator for optical applications - Case study Slava Krylov, Israel Tel Aviv University
16.45	Tool based micro and nano machining Lim-Siak Piang, Singapore National University of Singapore
17.00	Nano on micro devices Isao Shimoyama, Japan University of Tokyo
17.15	From Lab-on-Chip to Lab-in-a-Cell Albert Van Den Berg, Benelux Region University of Twente, The Netherlands
17.30	Biochips : trends and challenges Pierre Puget, France CEA-Léti
17.45	End of day 2
19.00	Departure for dinner at La Bastille

Wednesday, 5 May - Technical Tour